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(54) **OLED PIXEL DEFINING STRUCTURE WITH AT LEAST TWO INTERCOMMUNICATED SUB-PIXEL DEFINING ZONES OF SAME COLOR, MANUFACTURING METHOD THEREOF AND ARRAY SUBSTRATE**

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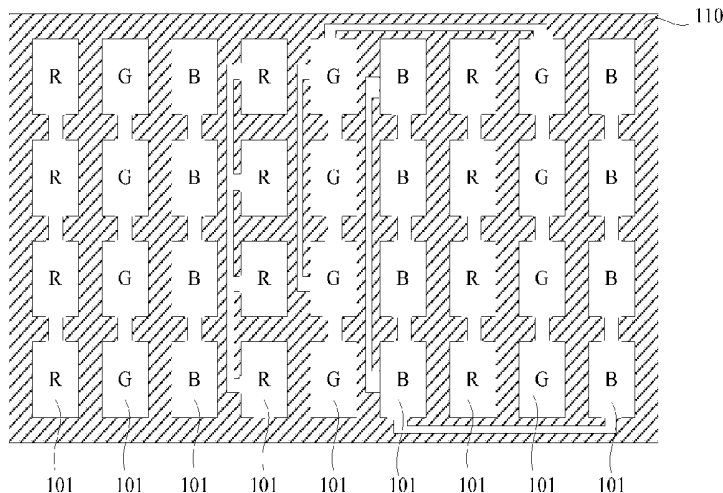
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*Primary Examiner* — Kevin Parendo

(57) **ABSTRACT**

There are provided an OLED pixel defining structure, a manufacturing method thereof and an array substrate. The OLED pixel defining structure includes a pixel defining layer, with a plurality of openings corresponding to sub-pixels of different colors being included in the pixel defining layer, each of the openings forming a sub-pixel defining zone of a corresponding color, wherein at least two sub-pixel defining zones of the same color are intercommunicated.

**16 Claims, 3 Drawing Sheets**



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*H01L 51/56* (2006.01)
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*H01L 51/56* (2013.01); *H01L 2227/323*  
 (2013.01)

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 See application file for complete search history.

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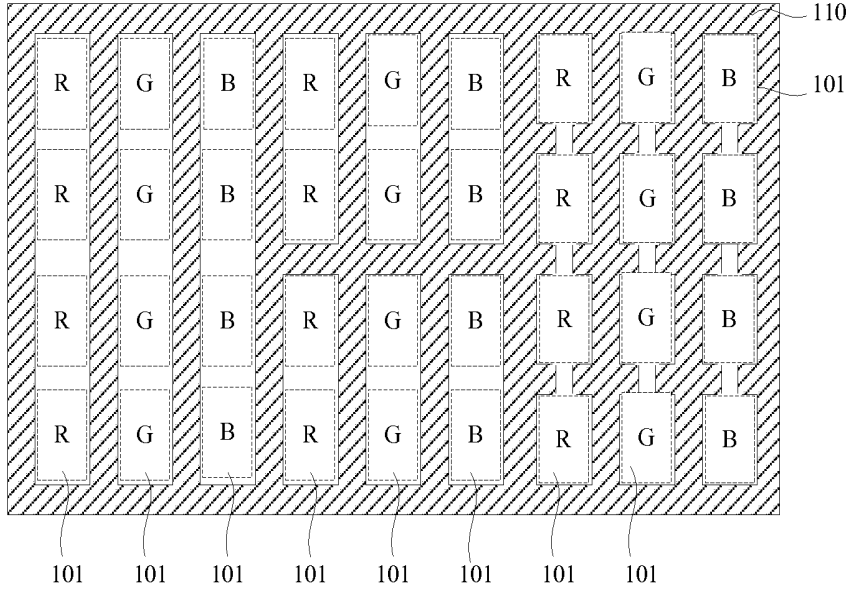


FIG. 1

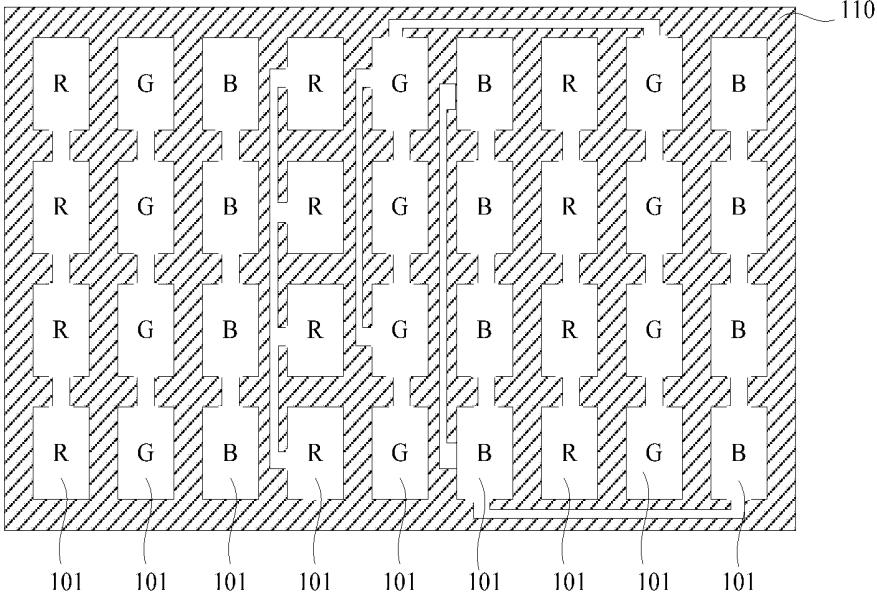


FIG. 2

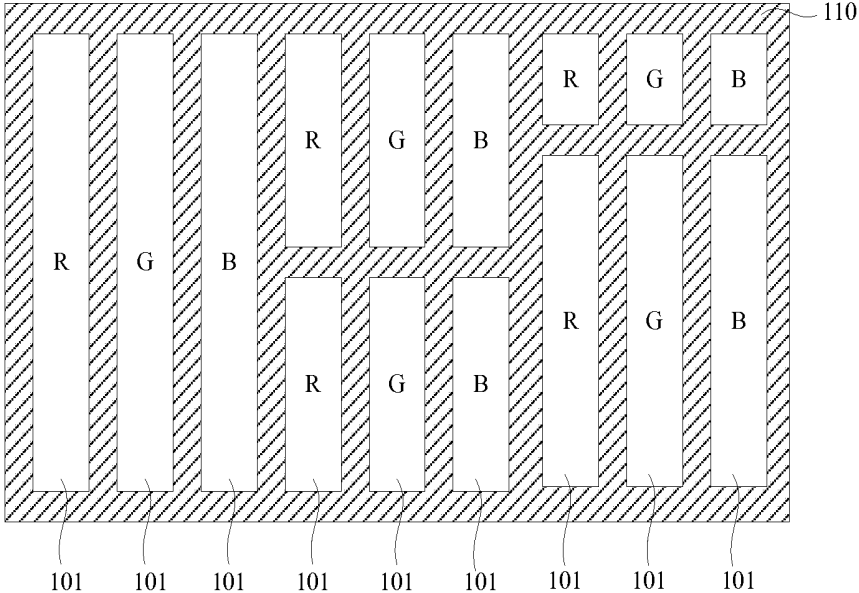


FIG. 3

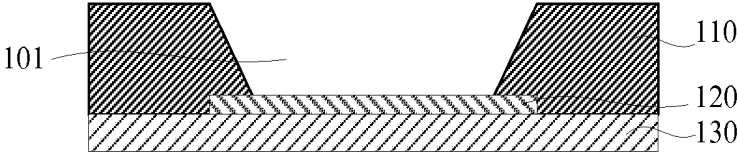


FIG. 4

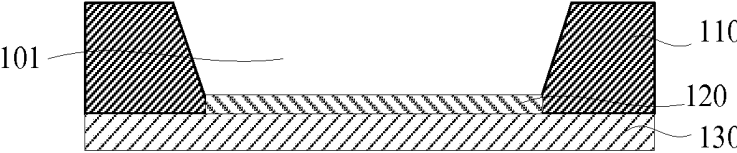


FIG. 5

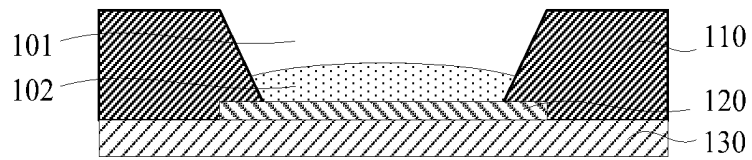


FIG. 6

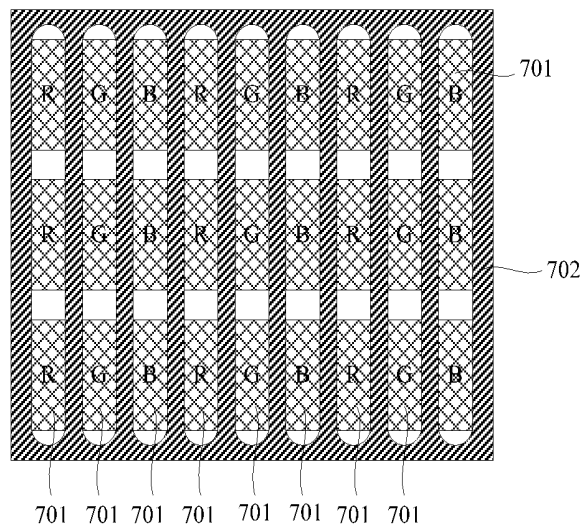


FIG. 7

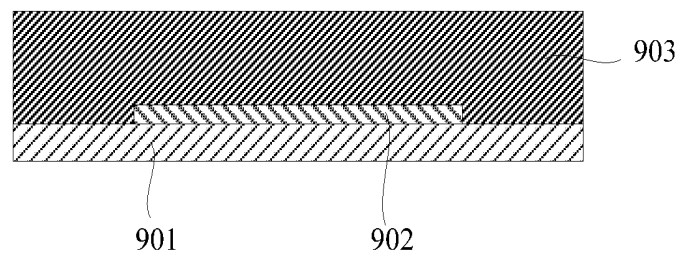


FIG. 8

**OLED PIXEL DEFINING STRUCTURE WITH  
AT LEAST TWO INTERCOMMUNICATED  
SUB-PIXEL DEFINING ZONES OF SAME  
COLOR, MANUFACTURING METHOD  
THEREOF AND ARRAY SUBSTRATE**

CROSS REFERENCE TO RELATED  
APPLICATIONS

This application is based on International Application No. PCT/CN2013/087386 filed on Nov. 19, 2013, which claims priority to Chinese National Application No. 201310205843.0 filed on May 29, 2013. The entire contents of each and every foregoing application are incorporated herein by reference.

FIELD OF THE INVENTION

Embodiments of the present invention relate to an OLED pixel defining structure, a manufacturing method thereof and an array substrate.

BACKGROUND

An Organic Light Emitting Diode (OLED) has such unique features that it is self-emissive, fast response, and wide viewing angle, can be made on a flexible substrate, and so on, and display based on OLEDs is becoming the mainstream in the field of display.

An OLED display back panel comprises a TFT substrate, an ITO (Indium Tin Oxide) pixel electrode, a light emitting layer, a cathode, etc. A pixel defining layer is produced on the TFT substrate, and each pixel defining zone of it corresponds to one pixel electrode. The finer and denser each pixel defining zone and a pixel electrode corresponding to each pixel defining zone are, the higher the resolution of products is, but the finely divided pixel defining zone has been limited by printing technology. With the size of a pixel defining zone being  $30\ \mu\text{m}\times 90\ \mu\text{m}$  as an example, when diameter of droplets formed by an inkjet head of a printer is equal to  $30\ \mu\text{m}$ , it is at the same level as size of a pixel. When an OLED device is fabricated with the ink-jet printer, it is necessary to take control of droplets, so that they precisely fall onto a pixel defining zone, and thickness of a thin film is uniform after the droplets falling into the pixel defining zone have been dried.

In prior art, control of precisely falling onto the pixel defining zone of droplets needs a printing equipment with a high alignment accuracy, and this requires increasing of the investment of equipment, leading to a higher cost. Furthermore, it is hard to form a thin film with a uniform thickness due to the fact that size of the pixel defining zone is smaller and flowability of the liquid is poor, and thus the quality of emission of the display back panel is affected.

SUMMARY

According to embodiments of the present invention, there is provided an OLED pixel defining structure comprising a pixel defining layer, the pixel defining layer containing a plurality of openings corresponding to sub-pixels of different colors therein, each of the openings forming a sub-pixel defining zone of a corresponding color, wherein at least two sub-pixel defining zones of a same color are intercommunicated.

According to an embodiment of the invention, there is provided a manufacturing method of an OLED pixel defining structure, comprising:

applying a layer of photoresist on a pixel electrode, so as to form a photoresist thin film for pixel definition; conducting a patterning treatment on the photoresist thin film for pixel definition, so as to form a pixel defining layer; wherein at least two sub-pixel defining zones of a same color in the pixel defining layer are intercommunicated.

The OLED pixel defining structure in embodiments of the invention comprises the pixel defining layer; and the pixel defining layer comprises sub-pixel defining zones of different colors, wherein at least two sub-pixel defining zones of the same color are intercommunicated. As at least two sub-pixel defining zones of the same color in the pixel defining layer are intercommunicated, and droplets fall into the intercommunicated sub-pixel defining zones, the intercommunicated sub-pixel defining zones are full of liquid with the aid of the flowability of liquid; and furthermore, as the flowability of liquid is increased in view of intercommunication of at least two sub-pixel defining zones, it is easier to form a thin film with a uniform thickness within the sub-pixel defining zones. Thus, the quality of emission of the display back panel is improved.

BRIEF DESCRIPTION OF DRAWINGS

In order to illustrate the technical solution of the embodiments of the invention more clearly, the drawings of the embodiments will be briefly described below; it is obvious that the drawings as described below are only related to some embodiments of the invention, but not limitative of the invention.

FIG. 1 is a schematic view illustrating an OLED pixel defining structure in an embodiment of the invention;

FIG. 2 is a schematic view illustrating intercommunication of one sub-pixel defining zone with sub-pixel defining zones of the same color through channels;

FIG. 3 schematically illustrates that no pixel defining layer exists between two sub-pixel defining zones of the same color that are intercommunicated in an embodiment of the invention;

FIG. 4 is a schematic view illustrating an OLED pixel defining structure in which a sub-pixel defining zone partially overlaps a corresponding pixel electrode in an embodiment of the invention;

FIG. 5 is a schematic view illustrating an OLED pixel defining structure in which a sub-pixel defining zone fully overlaps a corresponding pixel electrode in an embodiment of the invention;

FIG. 6 is a schematic view illustrating a sub-pixel light emitting layer of a sub-pixel defining zone in an embodiment of the invention;

FIG. 7 is a schematic view illustrating display of an OLED pixel defining structure in an embodiment of the invention;

FIG. 8 is a schematically sectional view illustrating a photoresist thin film for pixel definition that is coated on a substrate in an embodiment of the invention.

DETAILED DESCRIPTION

In order to make objects, technical details and advantages of the embodiments of the invention apparent, hereinafter, the technical solutions of the embodiments of the invention will be described in a clearly and fully understandable way in connection with the drawings related to the embodiments

of the invention. It is obvious that the described embodiments are just a part but not all of the embodiments of the invention. Based on the described embodiments of the invention, those ordinarily skilled in the art can obtain other embodiment(s), without any inventive work, which come(s) within the scope sought for protection by the invention.

The OLED pixel defining structure in embodiments of the invention comprises a pixel defining layer; and the pixel defining layer comprises sub-pixel defining zones of different colors, wherein at least two sub-pixel defining zones of the same color are intercommunicated. As at least two sub-pixel defining zones of the same color in the pixel defining layer are intercommunicated, and droplets fall into the intercommunicated sub-pixel defining zones, the intercommunicated sub-pixel defining zones are full of liquid with the aid of the flowability of liquid. Furthermore, as the flowability of liquid is increased in view of intercommunication of at least two sub-pixel defining zones, it is easier to form a thin film with a uniform thickness within the sub-pixel defining zones. Thus, the quality of emission of the display back panel is improved.

Hereinafter, embodiments of the invention will be further described in detail in combination with accompanied drawings of the specification.

As illustrated in FIG. 1, which is a schematic view illustrating an OLED pixel defining structure in an embodiment of the invention, the pixel defining structure comprises a pixel defining layer **110** that comprises sub-pixel defining zones **101** of different colors. The pixel defining structure in FIG. 1 is illustrated as an example, in which sub-pixel defining zones in each column of the pixel defining structure are sub-pixel defining zones of the same color, and sub-pixel defining zones comprises red sub-pixel defining zones R, green sub-pixel defining zones G and blue sub-pixel defining zones B, and the other circumstance is in an analogous fashion to it. At least two sub-pixel defining zones **101** of the same color are intercommunicated, and in the figure, that illustrated by dotted lines is one sub-pixel defining zone, and that illustrated by solid lines are the intercommunicated sub-pixel defining zones.

Intercommunication of at least two sub-pixel defining zones **101** of the same color comprises two cases, and they will be introduced below, respectively.

Case 1, one sub-pixel defining zone **101** is intercommunicated with a sub-pixel defining zone **101** of the same color as it through a channel, and width of the channel between sub-pixel defining zones is smaller than width of the sub-pixel defining zones.

As illustrated in FIG. 2, with sub-pixel defining zones in the same column being sub-pixel defining zones of the same color as an example, "R" in the figure represents a red sub-pixel defining zone, "G" represents a green sub-pixel defining zone, and "B" represents a blue sub-pixel defining zone. One sub-pixel defining zone **101** is intercommunicated with adjacent sub-pixel defining zones **101** of the same color as it through channels, and each sub-pixel defining zone **101** is intercommunicated at most with two adjacent sub-pixel defining zones **101** of the same color as it. Alternatively, sub-pixel defining zones **101** of the same color intercommunicate with each other through channels, that is, one sub-pixel defining zone **101** is intercommunicated at least with two sub-pixel defining zones **101** of the same color as it; and sub-pixel defining zones **101** of the same color in different columns may also intercommunicate through a channel. The communication mode of sub-pixel defining zones arranged in other manner through a channel that is smaller than a sub-pixel defining zone in width is similar to

the communication mode of sub-pixel defining zones in the same column, and details are omitted here.

Case 2, a channel between two adjacent sub-pixel defining zones **101** of the same color that are intercommunicated with each other has a width equal to that of the sub-pixel defining zones.

As illustrated in FIG. 3, with sub-pixel defining zones in the same column being sub-pixel defining zones of the same color as an example, a pixel defining layer between two sub-pixel defining zones **101** of the same color in the same column that are adjacent is removed, to form one sub-pixel defining zone set; or a pixel defining layer between adjacent sub-pixel defining zones **101** of the same color in the same column is removed, to form two or more sub-pixel defining zone sets. Sub-pixel defining zone sets of the same color in different columns may be intercommunicated through a channel. The communication mode of sub-pixel defining zones arranged in other manner through a channel having the same width as a sub-pixel defining zone is similar to the communication mode of sub-pixel defining zones in the same column, and details are omitted here.

In an example, sub-pixel defining zones are a plurality of openings formed within the pixel defining layer. Each of the openings corresponds to one sub-pixel defining zone. The plurality of openings may be formed on a substrate in the form of a two-dimensional array. Regarding a channel through which different sub-pixel defining zones of the same color are intercommunicated, it is obtained by removing a part of the pixel defining layer as well. The depth of a channel may be equal to the depth of an opening. And, the depth of a channel may also be smaller than depth of an opening, but in order to guarantee flow of an organic light emitting material within the intercommunicated sub-pixel defining zones, a difference between depth of the opening and depth of the channel is preferably smaller than thickness of an organic luminous layer to be formed within the sub-pixel defining zones.

The pixel defining structure further comprises pixel electrodes **120** below the sub-pixel defining zones **101**; the pixel electrodes **120** correspond to the sub-pixel defining zones **101** on a one-to-one basis, and a sub-pixel defining zone **101** partially or fully overlaps a corresponding pixel electrode **120**. As illustrated in FIG. 4, which is a case where a sub-pixel defining zone **101** partially overlaps a corresponding pixel electrode **120**, the pixel defining structure comprises a pixel defining layer **110**, pixel electrodes **120** and a TFT substrate **130**, wherein sub-pixel defining zones **101** are included in the pixel defining layer **110**; the pixel electrodes **120** are located over the TFT substrate **130**, the sub-pixel defining zones **101** are located over the pixel electrodes **120**, the sub-pixel defining zones **101** partially overlap the pixel electrodes **120**; on a region where the TFT substrate **130** is not covered by the pixel electrodes **120** and on a region where the pixel electrodes **120** are not covered by the sub-pixel defining zones **101** is the pixel defining layer **110**. As illustrated in FIG. 5, which is a case where a sub-pixel defining zone **101** fully overlaps a corresponding pixel electrode **120**, the pixel defining structure comprises a pixel defining layer **110**, pixel electrodes **120** and a TFT substrate **130**, wherein sub-pixel defining zones **101** are included in the pixel defining layer **110**; the pixel electrodes **120** are located over the TFT substrate **130**, the sub-pixel defining zones **101** are located over the TFT substrate **130**, the sub-pixel defining zones **101** fully overlap the pixel electrodes **120**; on a region where the TFT substrate **130** is not covered by the pixel electrodes **120** is the pixel defining layer **110**.

In an existing inkjet printing technology, owing to the restriction of size of inkjet droplets and the limitation in printing accuracy of a printer per se, it is very difficult to fabricate a display device with high resolution and high quality. In embodiments of the invention, there is no pixel defining layer between two adjacent sub-pixel defining zones **101** of the same color that intercommunicate with each other, and when a sub-pixel defining zone set is formed, an adverse effect brought by the printing accuracy error of an inkjet printing equipment can be decreased, thereby improving the quality of light emission of the display back panel. In one sub-pixel defining zone set, the emission area of the sub-pixel defining zone set is controlled by the area of a pixel electrode. When one pixel electrode is in a switched-on state, a corresponding region in a sub-pixel defining zone set corresponding to the pixel electrode is lit up; and other region of the sub-pixel defining zone set will not give off light if a corresponding pixel electrode is not switched on.

As illustrated in FIG. 6, a sub-pixel light emitting layer **102** formed of an organic light emitting material is contained in a sub-pixel defining zone **101**. As at least two sub-pixel defining zones of the same color are intercommunicated, it is easier to form a sub-pixel light emitting layer with a uniform thickness. Moreover, sub-pixel luminous layers **102** of different colors may differ in thickness.

Preferably, a second electrode is formed on the sub-pixel light emitting layer. FIG. 7 is a schematic view illustrating display of a pixel defining structure after a pixel defining layer between two adjacent sub-pixel defining zones of the same color that intercommunicate with each other is removed in an embodiment of the invention, wherein, “**701**” denotes a sub-pixel light emitting layer covered by a second electrode, and “**702**” denotes a substrate.

In embodiments of the invention, description has been given to an example in which in the OLED pixel defining structure, sub-pixel defining zones in one column are sub-pixel defining zones of the same color. Other case, such as the case where sub-pixel defining zones in one row are sub-pixel defining zones of the same color, or the case where adjacent sub-pixel defining zones are sub-pixel defining zones of the same color, is in an analogous fashion to it, and details are omitted here.

Further, according to an embodiment of the invention, there is further provided an OLED array substrate. The array substrate comprises a substrate, the pixel defining structure according to any of the above embodiments that is formed on the substrate, and sub-pixel light emitting layers formed within sub-pixel defining zones.

Based on the same inventive concept, there is further provided a manufacturing method of an OLED pixel defining structure according to an embodiment of the invention. As the principle to solve problems of the manufacturing method is similar to that of an OLED pixel defining structure according to an embodiment of the invention, implementation of the method may refer to implementation of the device, and repetitions are omitted here.

According to an embodiment of the invention, there is provided a manufacturing method of an OLED pixel defining structure, comprising:

Step **801**: a layer of photoresist is coated on a pixel electrode, so as to form a photoresist thin film for pixel definition;

Step **802**: a patterning treatment is conducted on the photoresist thin film for pixel definition, so as to form a pixel defining layer; wherein at least two sub-pixel defining zones of the same color in the pixel defining layer are intercommunicated.

Before a layer of photoresist is coated on the pixel electrode in step **801**, it further comprises forming the pixel electrode on a substrate.

The step **801** concretely comprises: a polymer photoresist solution is spin-coated or scratch-coated on a substrate containing a pixel electrode, and solvent in the solution is removed under a condition of low temperature, so as to form the photoresist thin film for pixel definition. As illustrated in FIG. 8, “**901**” denotes a substrate, “**902**” denotes a pixel electrode, and “**903**” denotes a photoresist thin film for pixel definition.

Conducting the patterning treatment on the photoresist thin film for pixel definition in step **802** comprises: the photoresist thin film for pixel definition is subjected to exposure and development to form pixel defining zones, wherein, at least two sub-pixel defining zones of the same color are intercommunicated.

As illustrated in FIG. 2 and FIG. 3, intercommunication of at least two sub-pixel defining zones of the same color comprises two cases:

Case 1, one sub-pixel defining zone is intercommunicated with a sub-pixel defining zone **101** of the same color as it through a channel, and width of the channel between sub-pixel defining zones is smaller than width of the sub-pixel defining zones. One sub-pixel defining zone is intercommunicated with adjacent sub-pixel defining zones of the same color as it through channels, and each sub-pixel defining zone is intercommunicated at most with two adjacent sub-pixel defining zones of the same color as it through channels. Alternatively, sub-pixel defining zones of the same color intercommunicate with each other through channels, that is, one sub-pixel defining zone is intercommunicated at least with two sub-pixel defining zones of the same color as it; and sub-pixel defining zones of the same color in different columns may also intercommunicate through a channel.

Case 2, a channel between two adjacent sub-pixel defining zones of the same color that are intercommunicated with each other has a width equal to that of the sub-pixel defining zones. Sub-pixel defining zones in the same column of the same color form one sub-pixel defining zone set; or sub-pixel defining zones in the same column of the same color form two or more sub-pixel defining zone sets. Sub-pixel defining zone sets of the same color in different columns may be intercommunicated through a channel.

In step **802**, a pixel defining layer is formed after patterning treatment is conducted on the photoresist thin film, and is subjected to a high-temperature annealing treatment, wherein sub-pixel defining zones of different colors are contained in the pixel defining layer.

The step **802** further comprises: a solution of an organic light emitting material having diverse colors drops into a corresponding sub-pixel defining zone, as the intercommunicated sub-pixel defining zones are more helpful for the flow of liquid, film-forming thickness for the solution of the organic light emitting material of the same color easily tends to be uniform too; and solvent in the solution of the organic light emitting material is removed, so as to form the sub-pixel light emitting layer with a uniform thickness illustrated in FIG. 5, wherein sub-pixel light emitting layers of different colors may differ in thickness. As long as the solution of the organic light emitting material drops within intercommunicated sub-pixel defining zones, a sub-pixel light emitting layer with a uniform thickness can be formed with the aid of the flowability of liquid. Thus, requirement on the accuracy of equipment is downgraded, and the cost of equipment is also reduced.

In an embodiment of the invention, there is provided a concrete manufacturing method of an OLED pixel defining structure, comprising:

Step **1001**: a desired number of pixel electrodes are formed on a substrate;

Step **1002**: a photoresist solution is spin-coated on the pixel electrode and the substrate not covered by the pixel electrode;

Step **1003**: solvent in the photoresist solution is removed under a condition of low temperature, so as to form a photoresist thin film for pixel definition;

Step **1004**: a patterning treatment is conducted on the photoresist thin film for pixel definition, so that at least two sub-pixel defining zones of the same color corresponding to the photoresist thin film for pixel definition are intercommunicated;

Step **1005**: a pixel defining layer that contains sub-pixel defining zones of different colors is formed;

Step **1006**: a solution of an organic light emitting material drops into the sub-pixel defining zones;

Step **1007**: solvent in the solution of the organic light emitting material is removed, so as to form a subpixel-defining-zone light emitting layer;

Step **1008**: a second electrode is deposited on the sub-pixel-defining zone light emitting layer through evaporation, printing.

Descriptions made above are merely exemplary embodiments of the invention, but are not used to limit the protection scope of the invention. The protection scope of the invention is determined by attached claims.

What is claimed is:

**1.** An OLED pixel defining structure, comprising a pixel defining layer containing a plurality of openings, the plurality of openings forming a plurality of sub-pixel defining zones of different colors, wherein

the plurality of sub-pixel defining zones are arranged into columns and rows, each of the columns extends in a first direction, and each of the rows extends in a second direction that is different from the first direction;

the sub-pixel defining zones in each of the columns have only one color, and the sub-pixel defining zones in each of the rows have different colors; and

at least two sub-pixel defining zones having a same color and provided in different columns intercommunicate with each other through a groove recessed in the pixel defining layer and guiding a liquid to flow only between the at least two sub-pixel defining zones.

**2.** The pixel defining structure of claim **1**, wherein the groove has a width smaller than or equal to widths of the plurality of sub-pixel defining zones.

**3.** The pixel defining structure according to claim **2**, wherein the groove has a depth equal to or smaller than depths of the plurality of openings.

**4.** The pixel defining structure according to claim **1**, wherein at least two sub-pixel defining zones having a same color and provided in a same column and different rows intercommunicate through another groove recessed in the pixel defining layer.

**5.** The pixel defining structure according to claim **1**, wherein the groove has a depth equal to or smaller than depths of the plurality of openings.

**6.** The pixel defining structure according to claim **1**, wherein the groove is continuous, one end of the groove is directly connected with one of the at least two sub-pixel defining zones, and the other end of the groove is directly connected with the other of the at least two sub-pixel defining zones.

**7.** An OLED array substrate, comprising:  
a substrate;

a pixel defining structure formed on the substrate, which comprises a pixel defining layer containing a plurality of openings, the plurality of openings forming a plurality of sub-pixel defining zones of different colors; and

sub-pixel light emitting layers formed within the sub-pixel defining zones, each sub-pixel light emitting layer being formed of an organic light emitting material of a corresponding color, wherein

the plurality of sub-pixel defining zones are arranged into columns and rows, each of the columns extends in a first direction, and each of the rows extends in a second direction that is different from the first direction;

the sub-pixel defining zones in each of the columns have only one color, and the sub-pixel defining zones in each of the rows have different colors; and

at least two sub-pixel defining zones having a same color and provided in different columns intercommunicate with each other through a groove recessed in the pixel defining layer and guiding a liquid to flow only between the at least two sub-pixel defining zones.

**8.** The array substrate of claim **7**, wherein the groove has a width smaller than or equal to widths of the plurality of sub-pixel defining zones.

**9.** The array substrate of claim **8**, wherein the groove has a depth equal to or smaller than depths of the plurality of openings, and a difference between the depth of the groove and the depths of the plurality of openings is smaller than thicknesses of the light emitting layers formed in the plurality of sub-pixel defining zones.

**10.** The array substrate of claim **8**, wherein the sub-pixel light emitting layers in the plurality of sub-pixel defining zones of different colors differ in thickness.

**11.** The array substrate of claim **7**, wherein the groove has a depth equal to or smaller than depths of the plurality of openings, and a difference between the depth of the groove and the depths of the plurality of openings is smaller than thicknesses of the light emitting layers formed in the plurality of sub-pixel defining zones.

**12.** The array substrate of claim **7**, wherein the sub-pixel light emitting layers in the plurality of sub-pixel defining zones of different colors differ in thickness.

**13.** The array substrate according to claim **7**, wherein at least two sub-pixel defining zones having a same color and provided in a same column and different rows intercommunicate through another groove recessed in the pixel defining layer.

**14.** The array substrate according to claim **7**, wherein the groove is continuous, one end of the groove is directly connected with one of the at least two sub-pixel defining zones, and the other end of the groove is directly connected with the other of the at least two sub-pixel defining zones.

**15.** A manufacturing method of an OLED pixel defining structure, comprising:

applying a layer of photoresist on a pixel electrode, so as to form a photoresist thin film for pixel definition;

conducting a patterning treatment on the photoresist thin film for pixel definition, so as to form a pixel defining layer; wherein the pixel defining layer contains a plurality of openings, the plurality of openings form a plurality of sub-pixel defining zones of different colors, the plurality of sub-pixel defining zones are arranged into columns and rows, each of the columns extends in a first direction, and each of the rows extends in a second direction that is different from the first direction;

sub-pixel light emitting layers formed within the sub-pixel defining zones, each sub-pixel light emitting layer being formed of an organic light emitting material of a corresponding color, wherein

the sub-pixel defining zones in each of the columns have only one color, and the sub-pixel defining zones in each of the rows have different colors; and at least two sub-pixel defining zones having a same color and provided in different columns intercommunicate with each other through a groove recessed in the pixel defining layer and guiding a liquid to flow only between the at least two sub-pixel defining zones.

**16.** The method of claim **15**, wherein the pixel defining layer between the sub-pixel defining zones of the same color that intercommunicate with each other is partially or fully removed, so that the groove between the sub-pixel defining zones has a width smaller than or equal to widths of the sub-pixel defining zones.

\* \* \* \* \*

专利名称(译)	具有至少两个相同颜色的互通子像素定义区的OLED像素定义结构，其制造方法和阵列基板		
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#### 摘要(译)

提供了一种OLED像素限定结构，其制造方法和阵列基板。OLED像素限定结构包括像素限定层，在像素限定层中包括与不同颜色的子像素相对应的多个开口，该多个开口中的每一个形成对应颜色的子像素限定区。至少两个相同颜色的子像素定义区域相互通信。

